NOTES:

- 1. SUBSTRATE: Fused Silica
- 2. COATING (APPLY ACROSS COATING APERTURE)

\$1: Laser Mirror (1064nm) R(ABS) >99.80% @ 1064nm @ 0-45° AOI

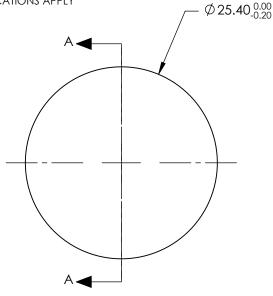
DAMAGE THRESHOLD, PULSED: 15 J/cm² @ 1064nm, 20ns, 20Hz

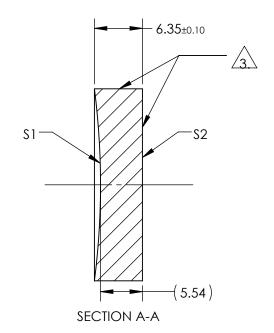
S2: NONE

3. FINE GRIND SURFACE

4. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS APPLY ACROSS CLEAR APERTURE

5. ROHS: COMPLIANT





FOR INFORMATION ONLY: DO NOT MANUFACTURE PARTS TO THIS DRAWING

	\$1	S2 PLANO INFINITY N/A N/A N/A	
SHAPE	CONCAVE		
RADIUS	100.00		
SURFACE QUALITY	20-10		
CLEAR APERTURE	Ø22.86		
COATING APERTURE	Ø22.86		
POWER AT 632.8nm	2 RINGS	N/A	
IRREGULARITY AT 632.8nm	0.10 WAVE	N/A	
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED	

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

	Edmund Option		;S®		
THIRD ANGLE PROJECTION		TITLE	25.4mm Dia. x 50mm EFL, 1064nm 0-45°, Concave Laser Line Mirror		
	ALL DIMS IN	mm	DWG NO	39967	SHEET 1 OF 1